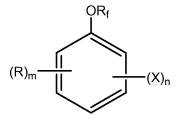
Listing of Claims

- 1. (Cancelled)
- 2. (Cancelled)
- 3. (Cancelled)
- 4. (Cancelled)
- 5. (Cancelled)
- 6. (Cancelled)
- 7. (Cancelled)
- 8. (Cancelled)
- 9. (Cancelled)
- 10. (Cancelled)
- 11. (Cancelled)
- 12. (Cancelled)
- 13. (Cancelled)
- 14. (Cancelled)
- 15. (Currently Amended) A liquid composition for depositing an active material onto a surface, said composition comprising:

an active material selected from electroluminescent materials; and at least one liquid medium for depositing an active material onto a surface selected from compounds having the structure



wherein:

R is C_1 - C_{10} alkyl, C_1 - C_{10} alkoxy, or C_1 - C_{10} oxyalkyl,

 R_f is C_2 - C_3 -fluorinated alkyl, C_1 - C_{10} fluorinated alkenyl, C_1 - C_{10} fluorinated oxyalkyl, or C_1 - C_{10} fluorinated oxyalkenyl,

X is H, F, Cl, Br, C₁-C₁₀ alkyl, C₁-C₁₀ alkoxy C₁-C₁₀ oxyalkyl, C₁-C₁₀ fluorinated alkyl, C₁-C₁₀ fluorinated alkenyl, C₁-C₁₀ fluorinated oxyalkyl, or C₁-C₁₀ fluorinated oxyalkenyl,

m is from 0-5, and

n is from 0-5, wherein m + n is no greater than 5.

- 16. (Cancelled)
- 17. (Cancelled)
- 18. (Cancelled)
- 19. (Cancelled)
- 20. (Cancelled)
- 21. (Cancelled)
- 22. (Currently Amended) A liquid composition for depositing an active material onto a surface, said composition comprising:

an active material selected from electroluminescent materials; and at least one liquid medium for depositing an active material onto a surface selected from compounds A through K, M through O and mixtures thereof:

OCF₂CF₂H OCF₂CF₂H OCF₂CF₂H OCF₂CF₂H OCF₂CF₂H
$$O$$
CF₂CF₂H O CF₂CF₂H

23. (Currently Amended) A liquid composition for depositing an active material onto a surface, said composition comprising:

an active material selected from electroluminescent materials; and at least one liquid medium for depositing an active material onto a surface selected from compounds having the structure

$$(R)_{m} \frac{\bigcap_{i \in \mathcal{X}} (X)_{n}}{\bigcap_{i \in \mathcal{X}} (X)_{n}}$$

wherein:

R and X are each, independently, C₁-C₁₀ alkyl, C₁-C₁₀ alkoxy, or C₁-C₁₀ oxyalkyl, R_f is C₂-C₃ fluorinated alkyl, C₁-C₁₀ fluorinated alkenyl, C₁-C₁₀ fluorinated oxyalkyl, or C₁-C₁₀ fluorinated oxyalkenyl, m is from 0-5, and n is from 0-5, wherein m + n is no greater than 5.

- 24. (Previously Presented) A liquid composition of claim 15 capable of forming a static contact angle of no greater than 40 degrees on said surface.
- 25. (Previously Presented) A liquid composition of claim 15 wherein the static contact angle is no more than 35 degrees.
- 26. (Previously Presented) A liquid composition of claim 15 wherein the static contact angle is no more than 20 degrees.
- 27. (Previously Presented) A liquid composition of claim 22 capable of forming a static contact angle of no greater than 40 degrees on said surface.
- 28. (Previously Presented) A liquid composition of claim 22 wherein the static contact angle is no more than 35 degrees.
- 29. (Previously Presented) A liquid composition of claim 22 wherein the static contact angle is no more than 20 degrees.
- 30. (Previously Presented) A liquid composition of claim 23 capable of forming a static contact angle of no greater than 40 degrees on said surface.
- 31. (Previously Presented) A liquid composition of claim 23 wherein the static contact angle is no more than 35 degrees.
- 32. (Previously Presented) A liquid composition of claim 23 wherein the static contact angle is no more than 20 degrees.
- 33. (Previously Presented) A liquid composition of claim 15 wherein depositing is by continuous deposition.

- 34. (Previously Presented) A liquid composition of claim 15 wherein depositing is by discontinuous deposition.
- 35. (Previously Presented) A liquid composition of claim 22 wherein depositing is by continuous deposition.
- 36. (Previously Presented) A liquid composition of claim 22 wherein depositing is by discontinuous deposition.
- 37. (Previously Presented) A liquid composition of claim 23 wherein depositing is by continuous deposition.
- 38. (Previously Presented) A liquid composition of claim 23 wherein depositing is by discontinuous deposition.